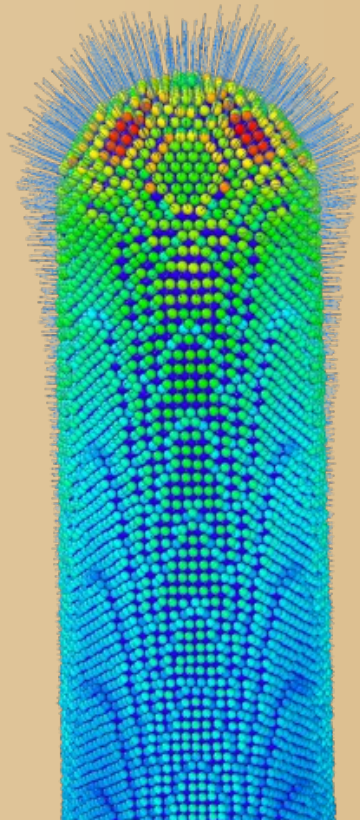


Thermal runaway of metal nano-tips during intense electron emission



A. Kyritsakis, M. Veske, K. Eimre,
V. Zadin, F. Djurabekova

Mini MeVArc 2017
Tartu 17.10.2017



Outline

- Motivation
- Methods:
 - Molecular Dynamics – Electrodynamics
 - Electron emission
 - Heat diffusion
- Results:
 - Thermal runaway in intensively emitting Cu nanotips
 - Evaporation rate – connection to plasma onset simulations
- Open questions - future plans
- Conclusions

Motivation

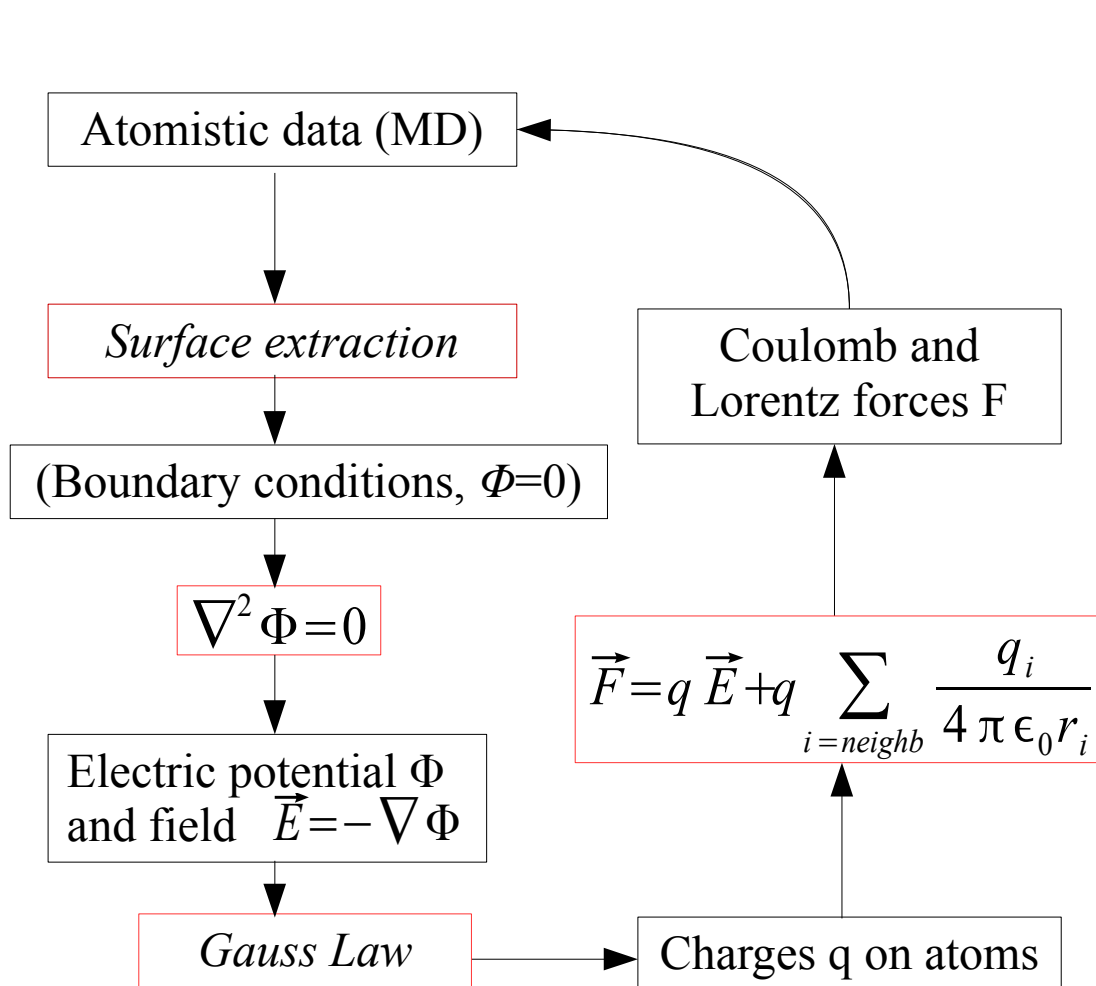
- Electron emission is known to initiate vacuum arcs. However, the exact mechanism is still unclear.
- Reveal and understand the mechanisms leading from **intense electron emission** to **plasma formation**
- Plasma PIC simulations [1]: plasma can ignite from a Cu field emitter assuming:
 - Intense field electron emission up to mA
 - Evaporation of Cu neutral atoms to a rate of 0.015 atoms/emitted e.
- **What is the origin of those neutrals?**
- **What mechanisms lead to their evaporation?**

[1]: H. Timko et. al., Contrib. Plasma. Phys. 4 , p229
(2015)

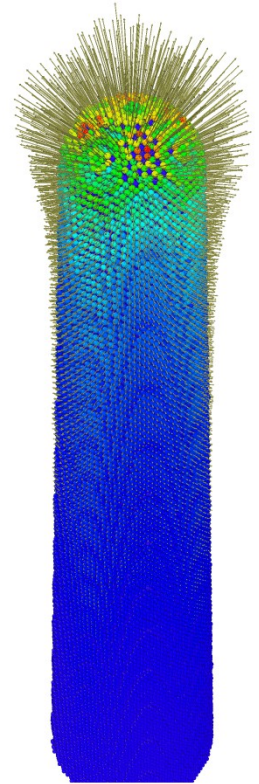
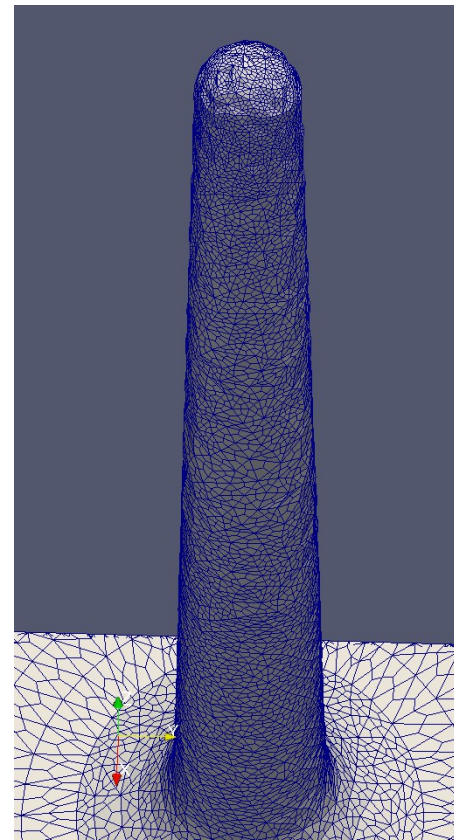
Need for multi-physics simulations

- Existing hypothesis:
 - Intense electron emission → heating → thermal-field-assisted evaporation
 - Is this evaporation enough??
- A simulation of this process must include:
 - Material deformations: *Molecular Dynamics*
 - Electric field effects: *Finite Element Method*
 - Electron emission: *GETELEC*
 - Heat diffusion: *Finite Difference Method*
- All the above processes have to be calculated

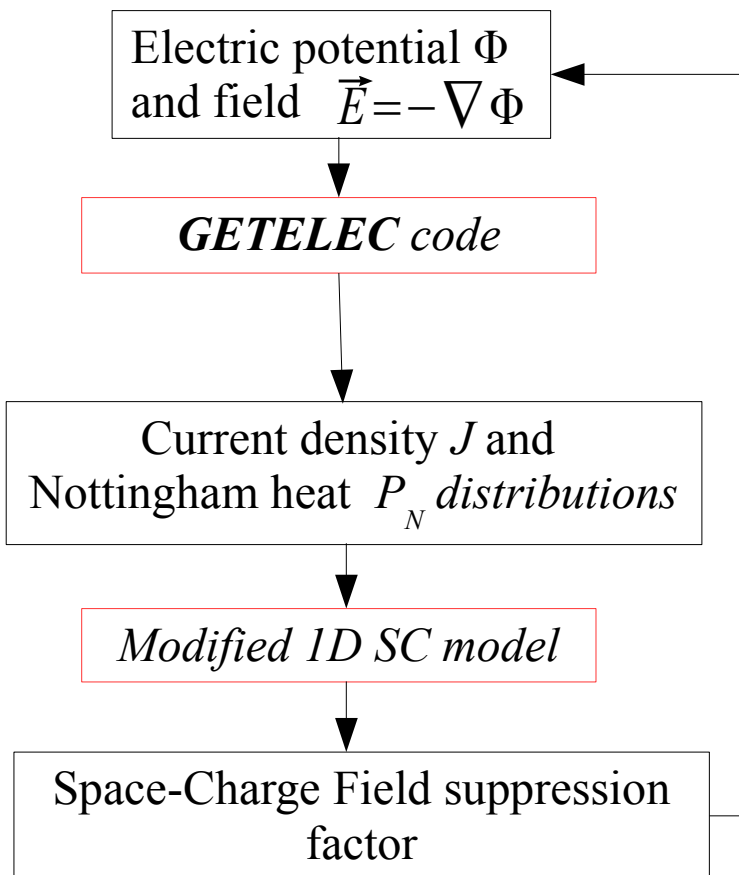
Concurrent MD-ED



$$h = 93\text{nm}, r = 3\text{nm}, \text{sa} = 3^\circ$$



Electron emission in the space-charge limited regime

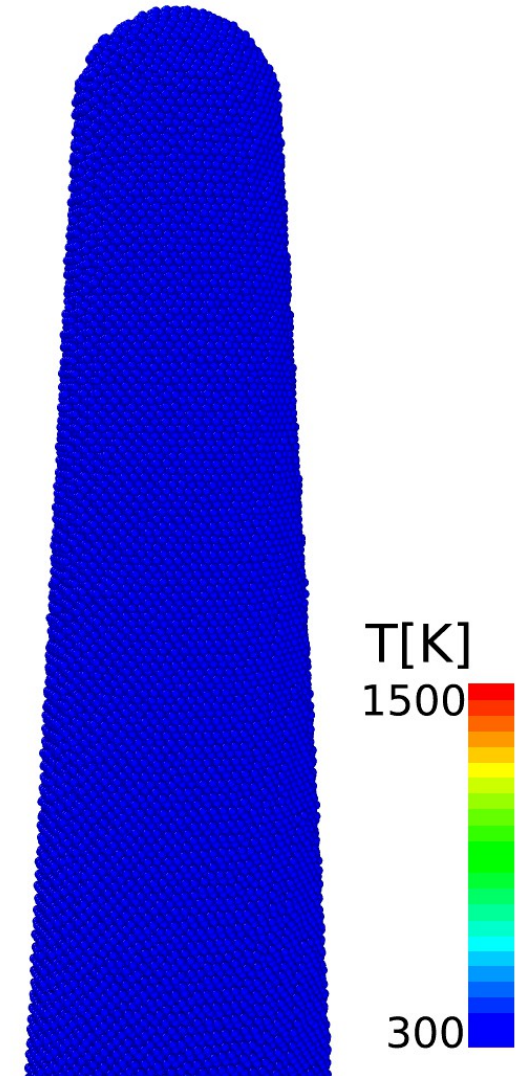
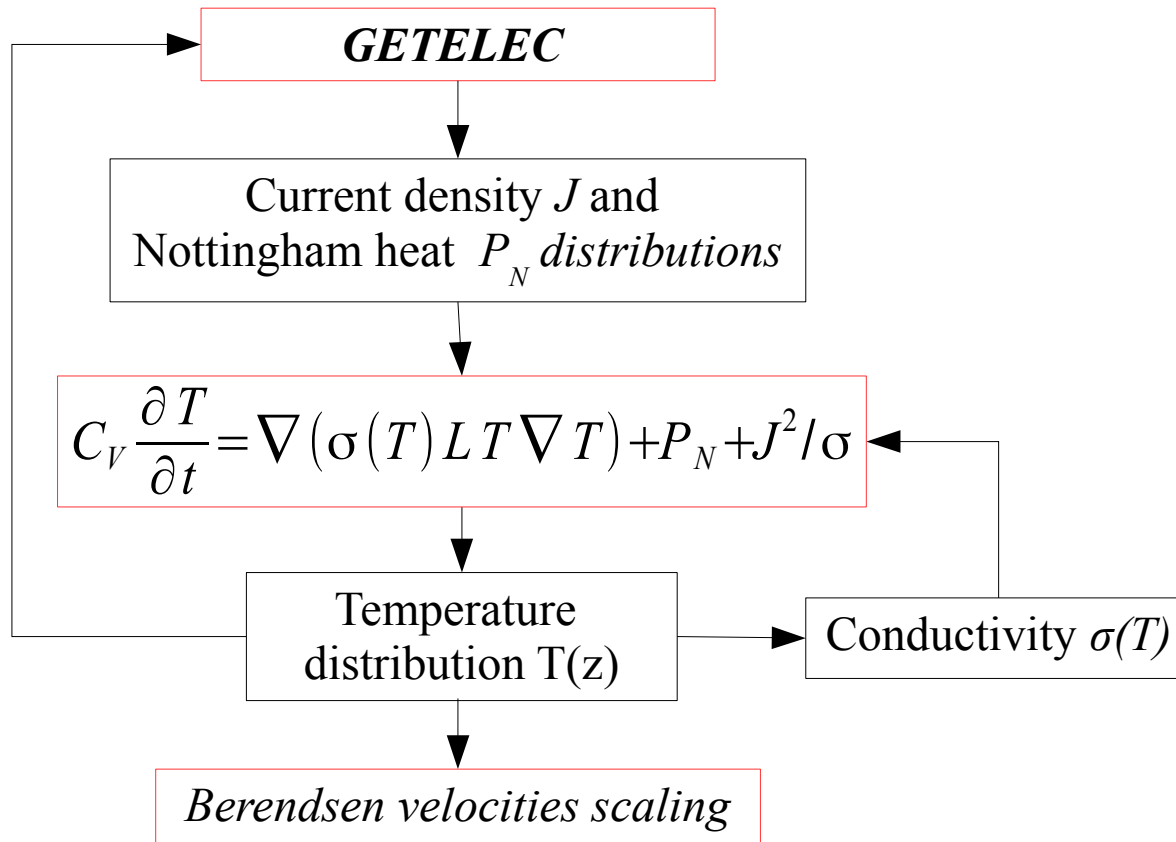


[1] I. Uimanov, IEEE Trans. Dielectr. Electr. Insul. 18, 924 (2011)

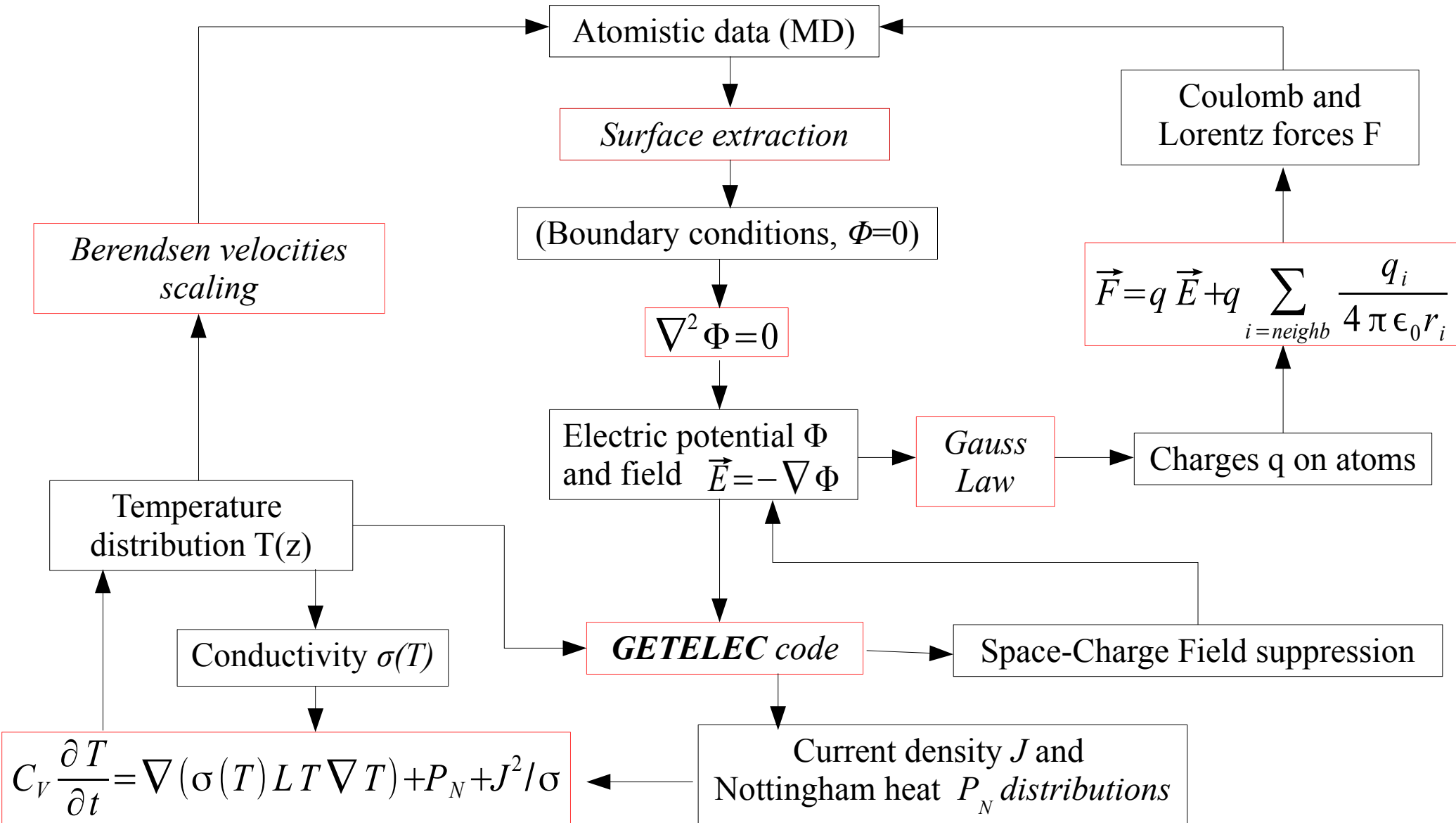
- Modified 1-D model: multiply the total voltage by $\omega < 1$, use representative values for \mathbf{E} , \mathbf{J} distributions
- Fitting to full 3D simulation data by Uimanov [1]
- Good agreement: The 1D SC model is sufficient

Heating: Joule and Nottingham

$t = 0.0 \text{ ps}$



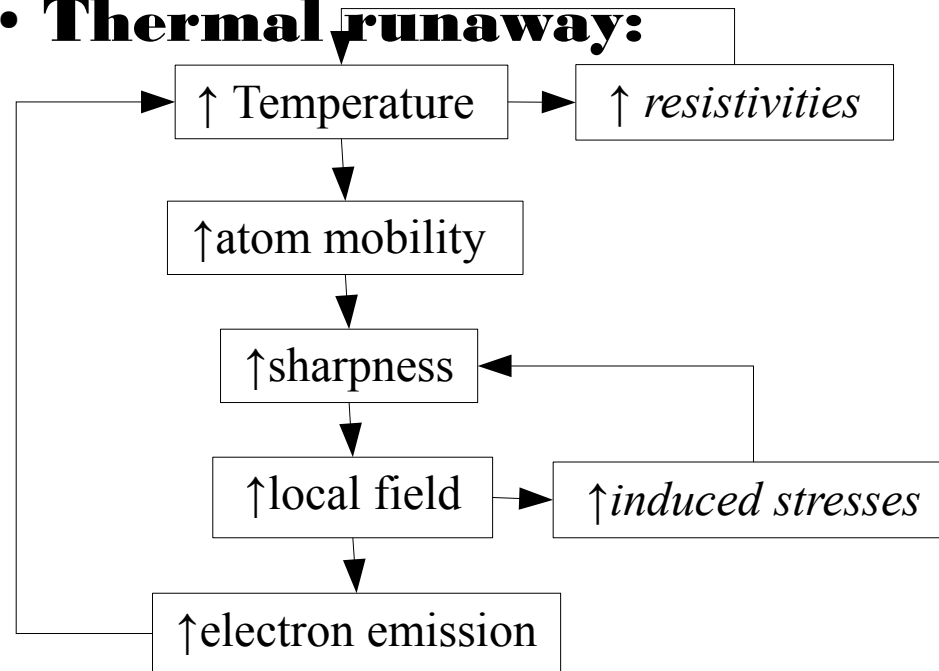
The whole simulation model



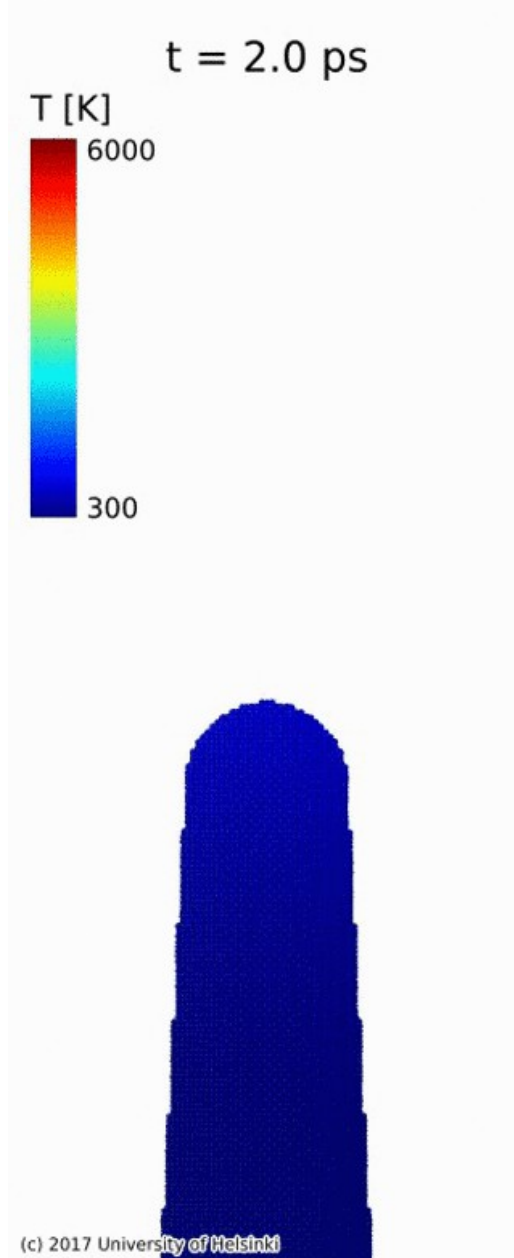
Results: Thermal runaway- evaporation

- Simulating for $E_{\text{appl}} = 0.8 \text{ GV/m}$, $V_{\text{appl}} = 3 \text{ kV}$
DC

- **Thermal runaway:**

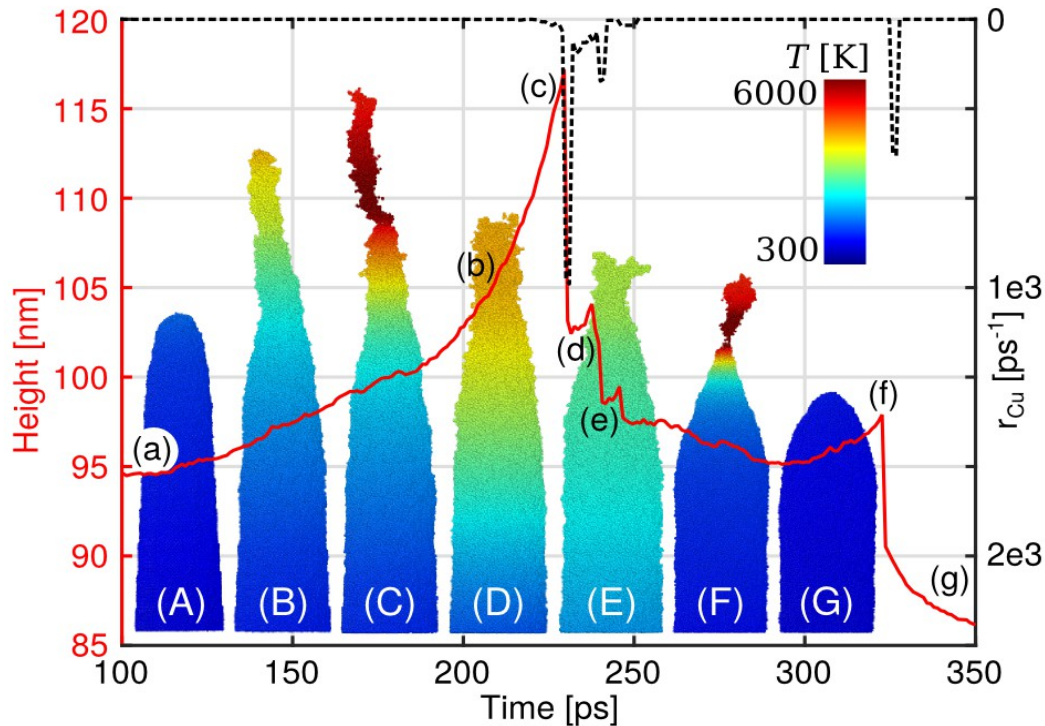


- **Evaporation** of large parts of the tip in forms of atoms and nanoclusters
- Eventually the tip has not enough length and it cools down gradually.





Evaporation analysis



- Tested for two different Cu inter-atomic potentials
- 7 independent runs for each potential with different seeds
- The same qualitative behaviour for all (the numbers might deviate)

- Mean evaporation rate between first and last evaporation events: $R_{Cu} = 75 \pm 11$ atoms/ps
- Mean current $I = 2807 \pm 153$ e/ps
- $R_{Cu/e} = 0.025 \pm 0.003$ atoms/e
- **Exceeds** the minimum 0.015 found in the ArcPIC simulations!!!

Conditions to runaway

- Prerequisites for the thermal runaway process to be initiated:
 - a) **Heating** enough to cause melting of a significant area at the apex region. T reach $\sim 1400-1500\text{K}$
 - b) **Current densities** that cause this high heating are of the order 10^{12} A/m^2 (agreement with experiments)
 - c) **Local field** at the top (after SC lowering) must be more than $\sim 10\text{GV/m}$ to “pull” the tip upwards
- Tips of 20-100nm height must be present to initiate this process

- **Still open questions:**

- What happens with the evaporated atoms and clusters?
- How do they affect the electrostatics?
- What is the transient effect of the space charge?

- **Further development:**

- Develop full 3D simulation for the space charge
- Simulate the impact of the nanoclusters on the anode
- Include the evaporated atoms in the electrostatic simulation
- Integrate PIC simulations in the vacuum region and track all evaporated particles until plasma ignition.

Conclusions

- The mechanism leading from intense field emission to vacuum arc has still a lot of questions to be answered
- The integrated multi-physics simulations can reveal and give an insight in several processes
- A **thermal runaway** process leads to **evaporation** of large parts of a nanotip in the form of both **atoms** and **nanoclusters**
- The number of evaporated atoms matches well the minimum number required in plasma simulations to initiate plasma
- Further investigation of the behaviour of the vapour is needed to understand the behaviour of mechanisms and fully connect to the plasma calculations.

Acknowledgements





Thank you!!!!